

### **REMARKS**

Process claims 55-57 were found allowable. Independent process claim 76 has been amended to include the language “after completion of the use of said exposed portions of said photo-definable layer as a patterned etch mask” similar to that used in independent process claim 55 as noted in the Office Action Allowable Subject Matter comments. Product claims 59-61 and 84-87 have been canceled.


As such it is respectfully asserted that each independent claim is patentably distinct from the cited art.

**Conclusion**

Applicants respectfully assert that the pending claims are in condition for allowance. Reconsideration of the application is respectfully requested.

The Examiner is invited to contact the undersigned at the phone number indicated below with any questions or comments or to otherwise facilitate expeditious and compact prosecution of the application.

Respectfully submitted,

  
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